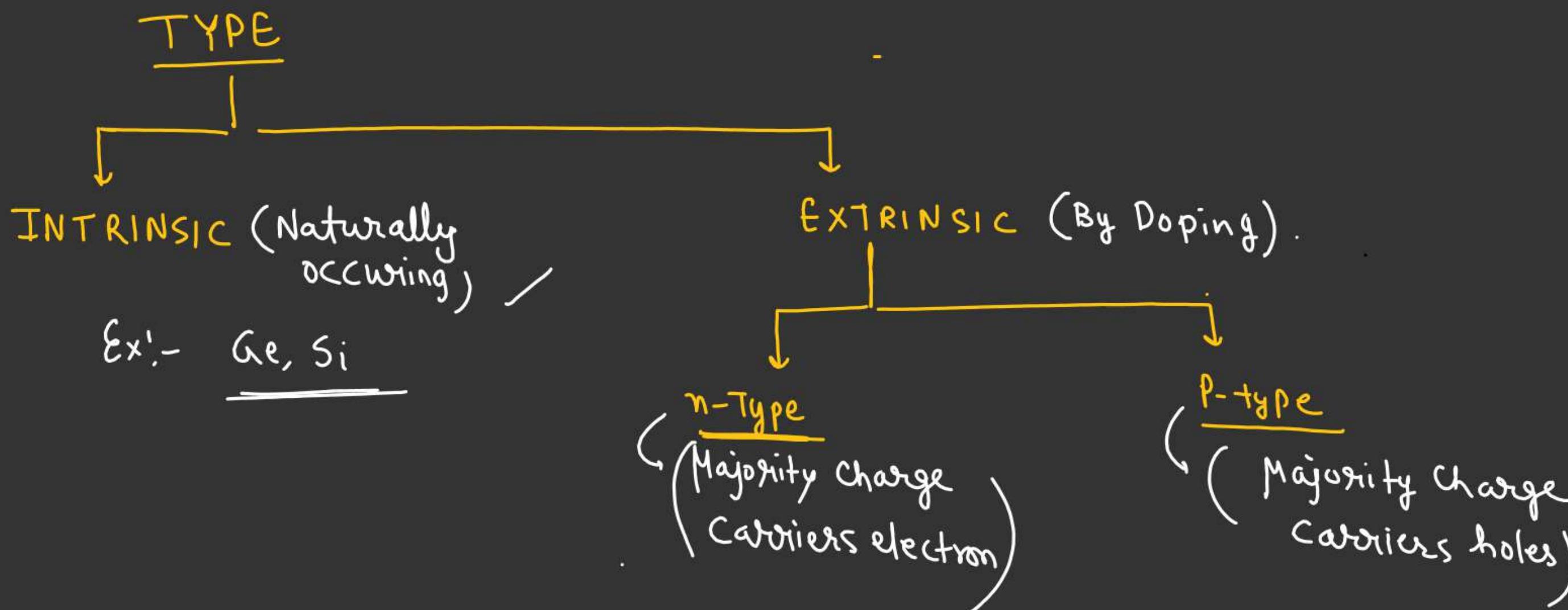


SEMI CONDUCTOR

- Much higher resistivity than metal.
- Temp coff of resistivity -ve & high
- Charge Carriers lower than metal.



INTRINSIC SEMI CONDUCTOR (PURE SEMI CONDUCTOR)

- Free from impurities ✓
- At OK behave as insulators
Temp.

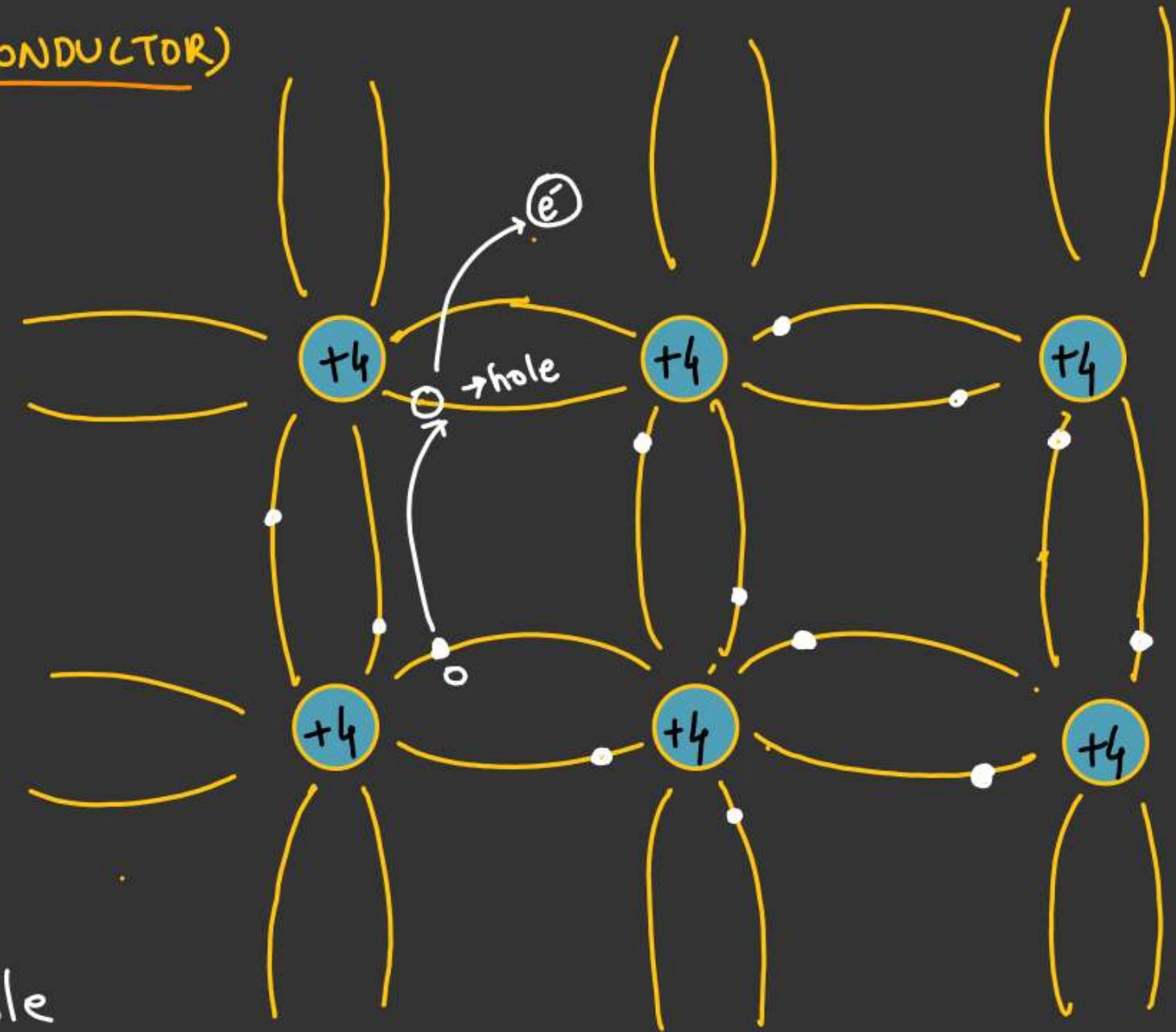
- At high temp, the thermal energy of Valance electron increases .

An electron may break away from the Co-valent bond & become free to conduct

- To free an electron from Co-valent bond and simultaneously creation of hole required a kind of ionisation energy E_g.

$$n_e = C e^{-E_g/2kT}$$

No of electrons, For given E_g, n increases as the temp increases.
Set free



→ Each free electron creates one hole, so in an intrinsic Semiconductor no of holes (N_h) and no of electrons (N_e) are equal.

$$\underline{N_e = N_h = N_i}$$

→ Total Current in intrinsic Semiconductor
is $I = \underline{(I_e + I_h)}$ ✓

DOPING :-



Addition of desirable impurity to a pure Semiconductor so as to increase its conductivity.



TYPE OF DOPANTS (IMPURITY)

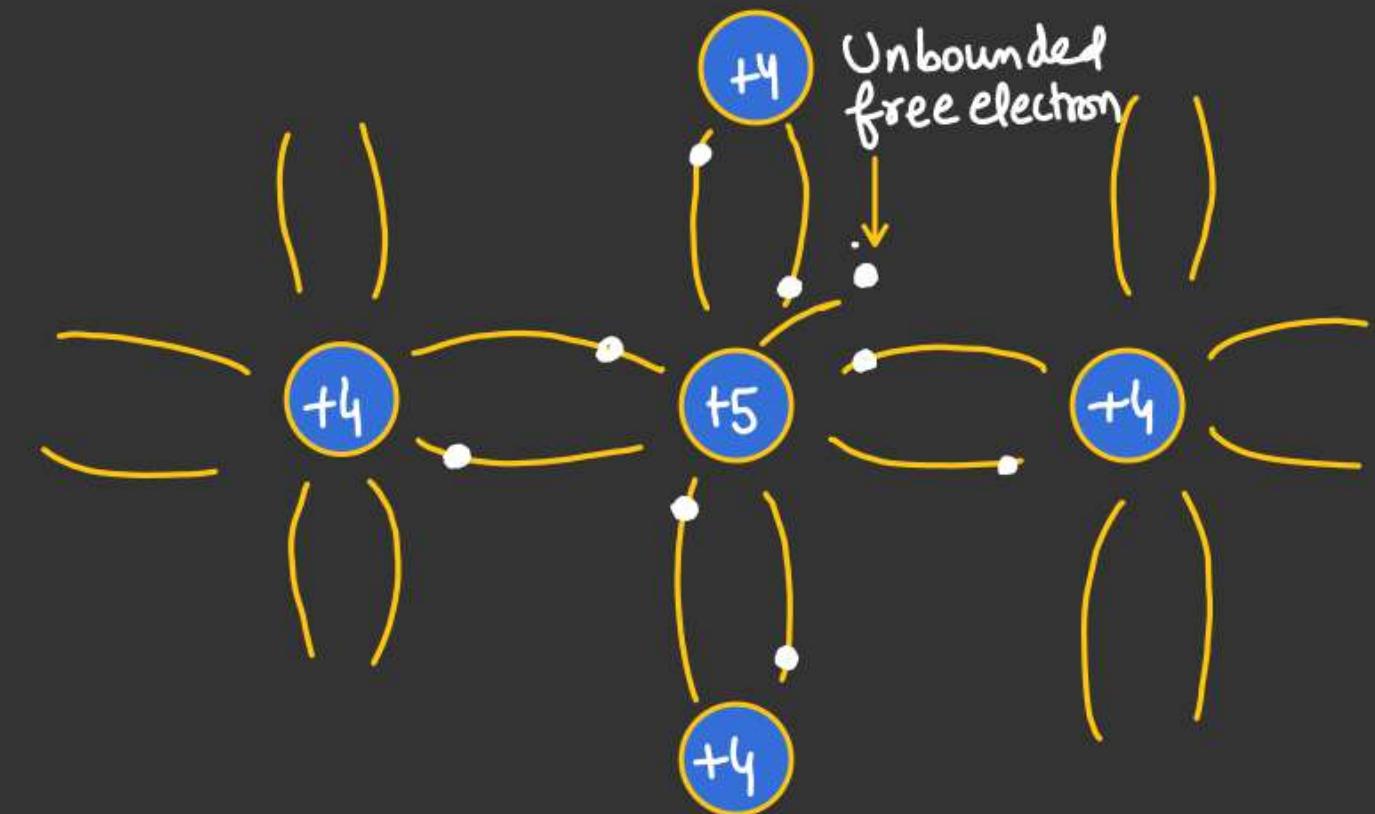
- ① Pentavalent \rightarrow 5 Valence electrons.
Arsenic (As), Antimony (Sb), & Phosphorous (P)
- ② Trivalent \rightarrow 3 Valence bond
Indium (In), Boron (B) & Aluminium (Al)

EXTRINSIC SEMICONDUCTORN-TYPE

- Doped with pentavalent impurity with Si or Ge.
- When pentavalent impurity atom substitutes the tetravalent Si atom it uses one of its 5 valence electrons in forming 4 covalent bonds with neighbouring Si atom while the 5th electron is loosely bound to the impurity atom.

A very small amount of ionisation energy ($\approx 0.01 \text{ eV}$) is required to free this e^-

- N-type semiconductors electrons are majority charge carriers.
 $(n_e \gg n_h)$



P-TYPE

→ Obtained by doping the trivalent impurity with Si or Ge.

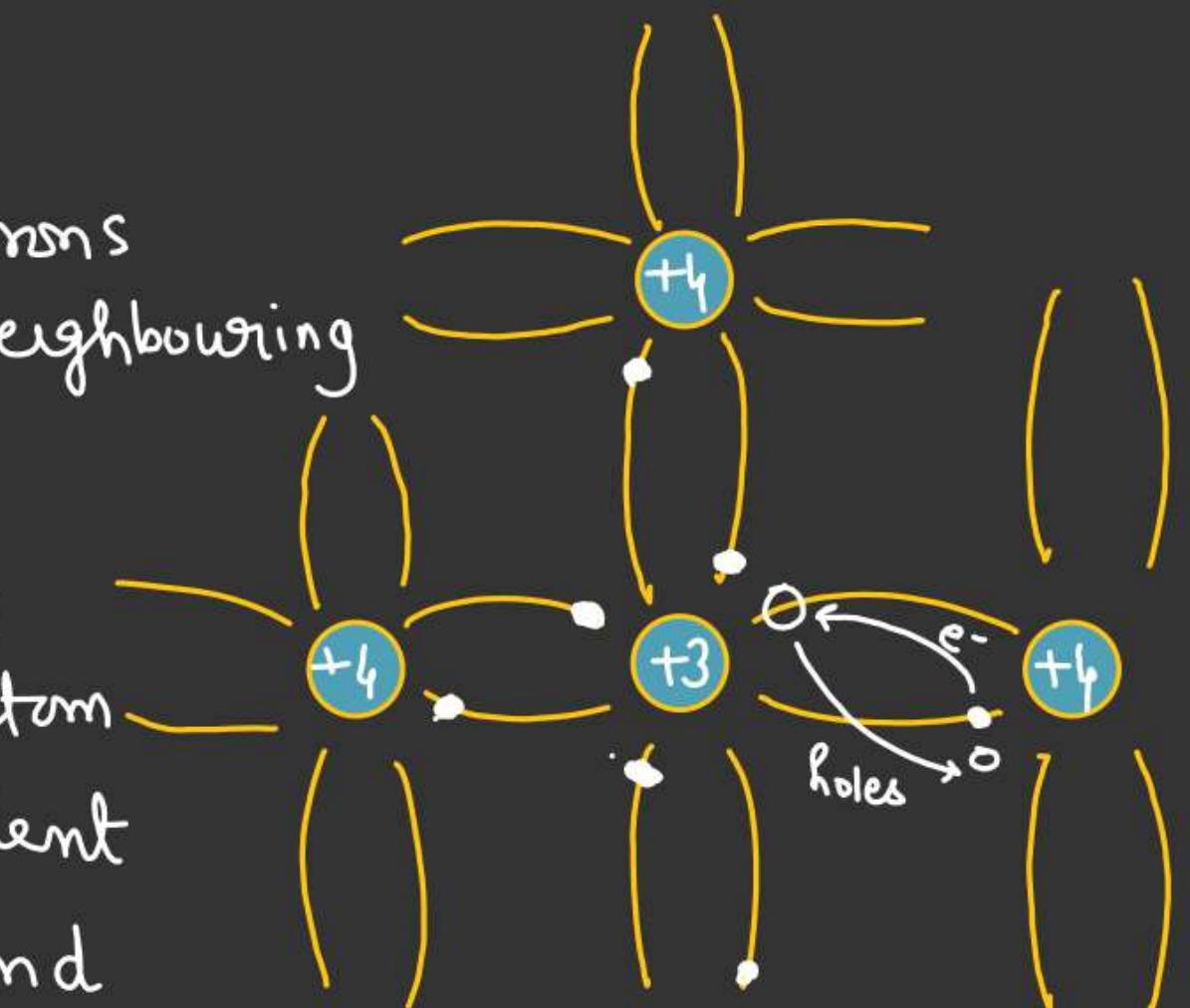
→ Impurity atoms uses its three valence electrons in forming co-valent bonds with three neighbouring Si atoms.

One co-valent bond with a neighbouring Si atom is left incomplete due to deficiency of atom.

An electron from neighbouring Si-Si co-valent bond can slide into this vacant bond (Creating a vacancy or hole in that bond).

→ Hole is now available for conduction
Current in P-type due to conduction of hole.

$$(n_h >> n_e)$$



⇒ For Semiconductor

$$n_e n_h = n_i^2$$

Concentration of electron Concentration of hole Intrinsic Charge Concentration

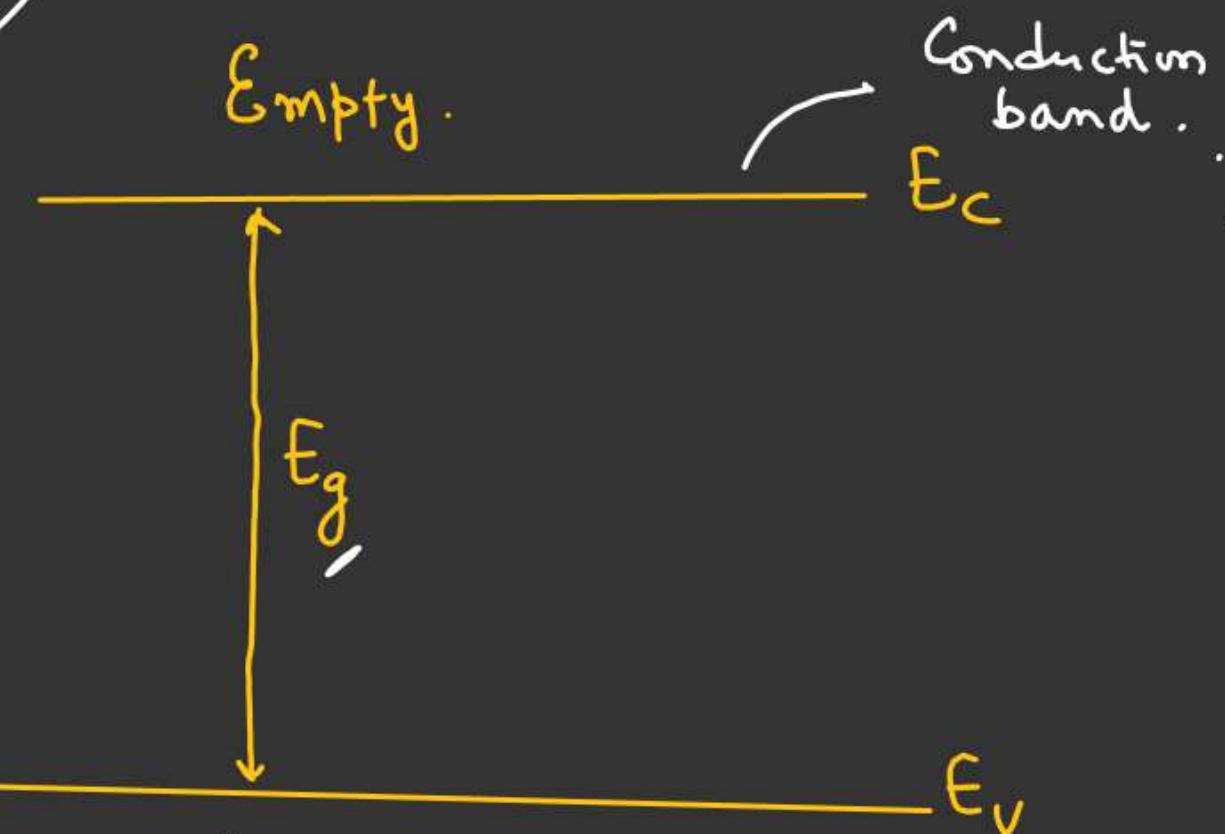
ENERGY BAND THEORY IN SOLIDS

→ Two Energy Bands
 Valence Band ✓
 conduction Band. ✓

→ E_v = Highest Valence band energy

E_c = Lowest conduction band energy

$$\boxed{E_g = E_c - E_v}$$



Valence band.

METALS \rightarrow (Valence band \rightarrow Completely filled) \quad (Conduction band \rightarrow Partially filled)

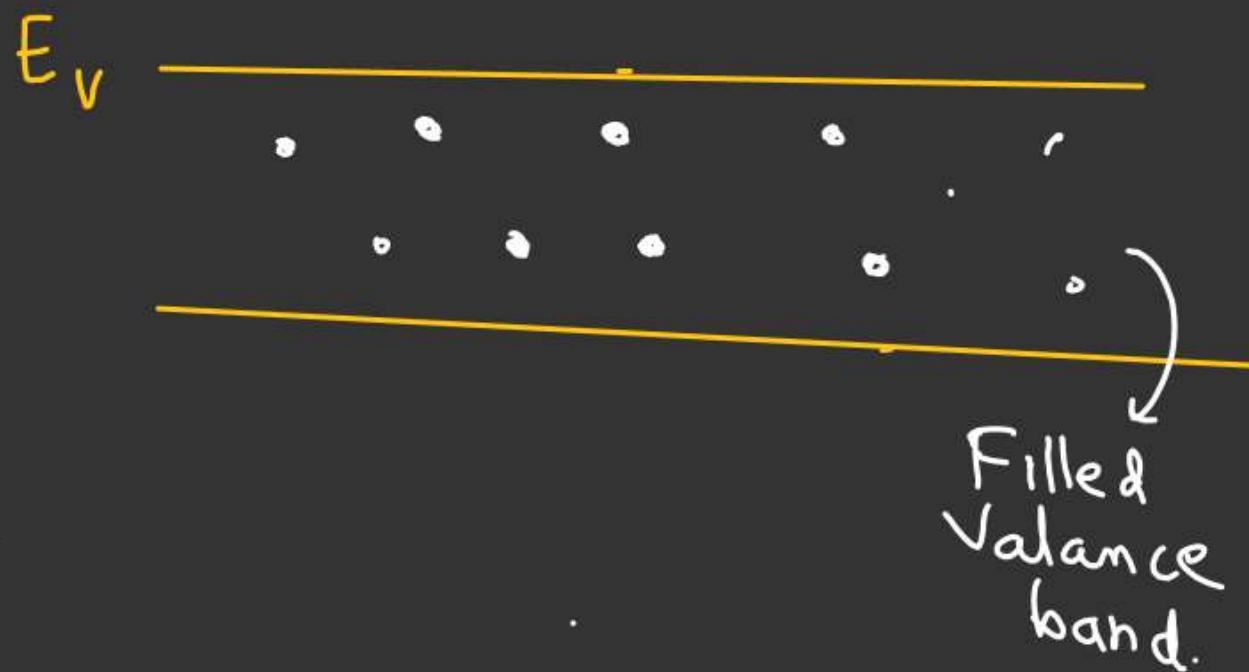
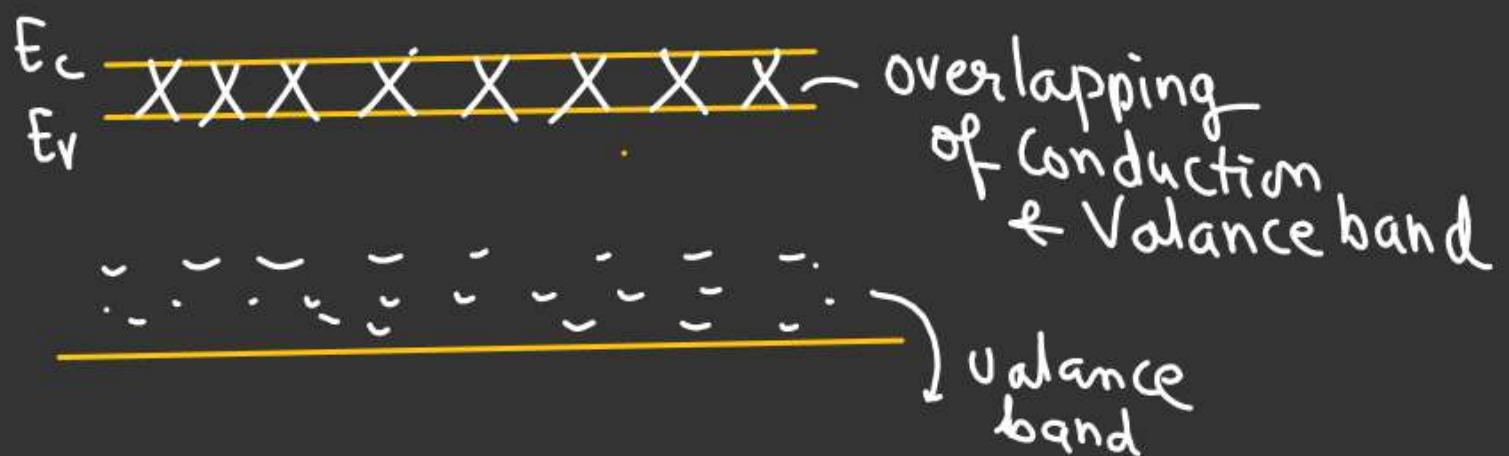
Two type of Energy band structure.

Either there is energy gap b/w the completely filled Valence band & the partially filled Conduction band.

Ex:- (Al Kali Metals, Noble Metals
third group Metals)

OR

Conduction and Valance band overlap.

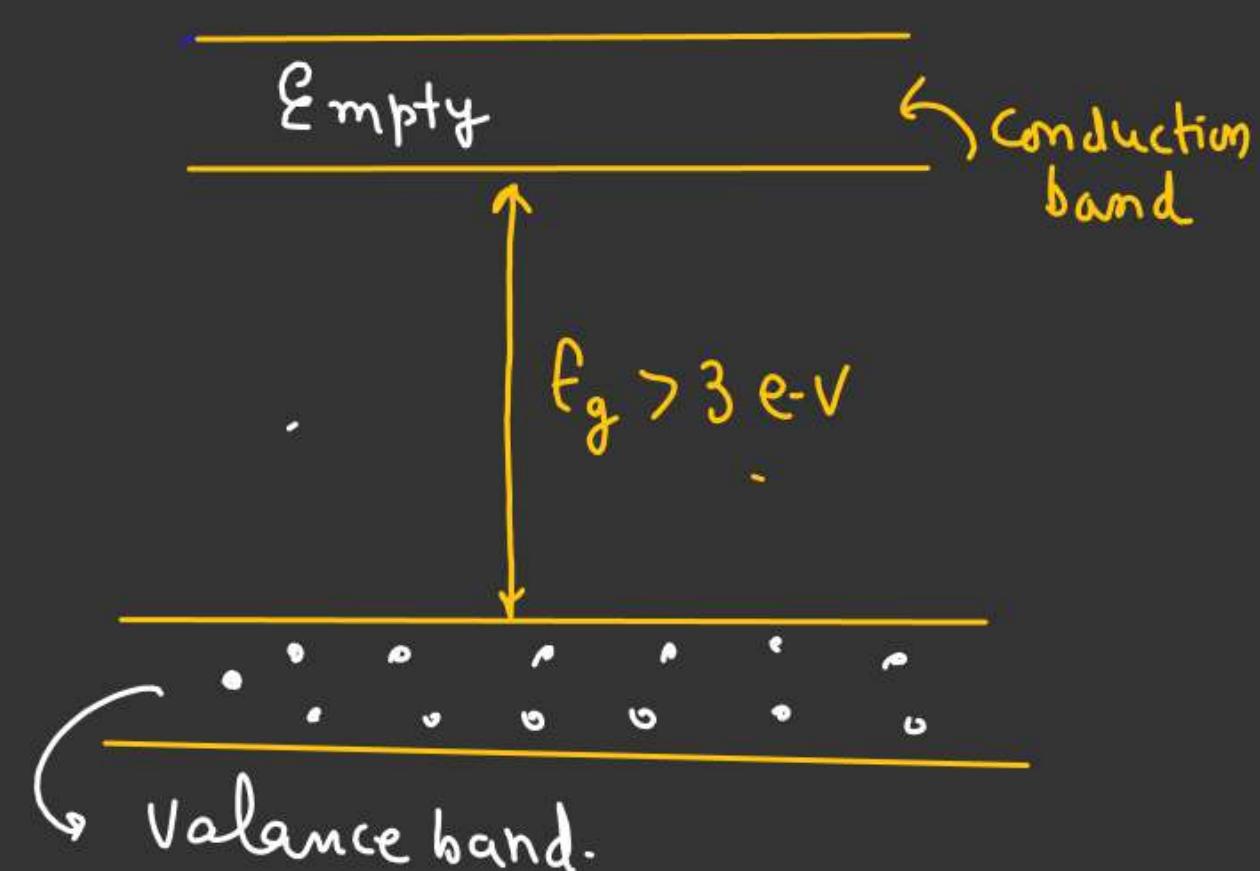


FERMI LEVEL

Highest Energy level in the conduction band at absolute zero is called FERMI LEVEL and energy corresponding to this level is called FERMI Energy level.

INSULATORS

- L In insulators, Valance band is completely filled while the conduction band is empty.
- L Large energy gap b/w the Valance band & conduction band ($E_g > 3 \text{ e-v}$)



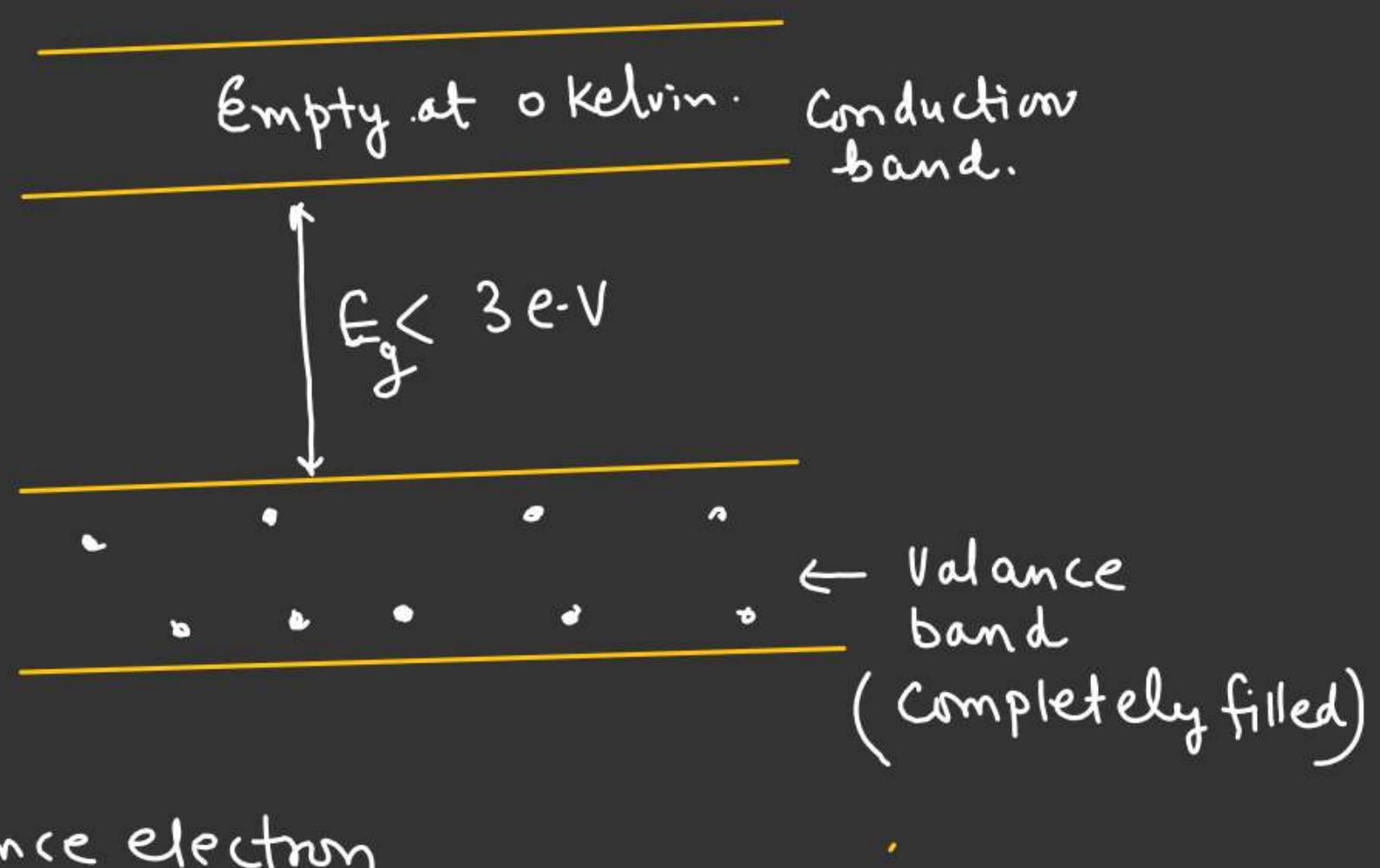
ENERGY BAND IN SEMI CONDUCTORINTRINSIC SEMICONDUCTOR

At 0K , conduction band empty.
 (Temp) Valence band completely filled

$$\begin{cases} E_g = 1.17 \text{ e-V for Si} \\ E_g = 0.74 \text{ e-V for Ge} \end{cases}$$

At higher temp ($> 0\text{K}$) Some valance electron jump to conduction band where they are free to conduct.

So Intrinsic Semiconductor acquires small conductivity above 0 Kelvin

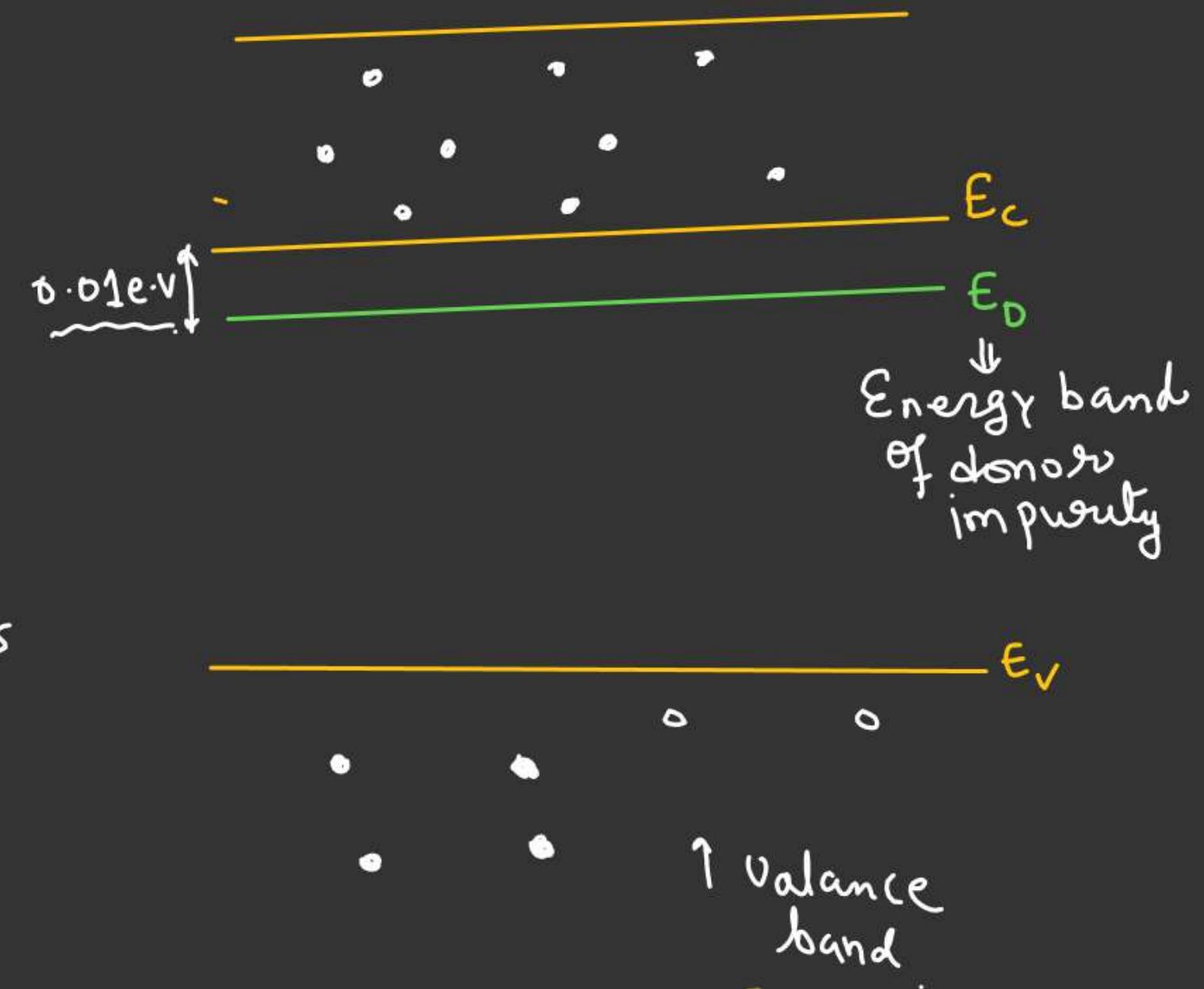


EXTRINSIC SEMICONDUCTORN-Type

Extra fifth electron is very weakly attracted by the donor impurity. A very small energy is required to free electrons from the donor impurity.

Imp

\Rightarrow Conduction band has more electrons as they have been contributed both in thermal excitation & donor impurity.



P-Type

- Each acceptor impurity creates a hole which can be easily filled by an electron of Si-Si covalent band.

A very small energy require by an electron of valance band to move into this hole.

Acceptor energy level Slightly above the Valance band.

